

Synthesis and Characterization of c-Axis Oriented Zinc Oxide Thin Films and Its Use for the Subsequent Hydrothermal Growth of Zinc Oxide Nanorods

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ABSTRACT

Oriented ZnO seed layers were deposited by three different techniques, namely, simple drop casting (DC), sol-gel derived dip coating (DPC) and spin coating of ball-milled ZnO powder solution (BMD) for the subsequent growth of vertically aligned ZnO nanorods along the substrate normal. X-ray diffraction (XRD) analyses revealed that ZnO(DC) seed layer exhibit the highest preferential c-axis texturing among the ZnO seed layers synthesized by different techniques. The Scanning Electron Microscopy (SEM) analysis evident that the morphology of ZnO seed layer surface is compact and coherently carpets the underlying substrate. ZnO nanorods were then grown by hydrothermal method atop the ZnO seeded and non-seeded substrates grown by different techniques to elucidate the best ZnO seed layer promoting well-aligned ZnO Nanorods. The presence of c-axis oriented ZnO(DC) seeding layers was found to significantly affect the surface morphology and crystallographic orientation of the resultant ZnO NRs films. The optical band gap of ZnO(DC) seed and ZnO NR were estimated to be 3.30 eV and in the range of 3.18 – 3.25 eV respectively by using UV-VIS-NIR diffuse reflection spectroscopy. The room temperature photoluminescence analyses revealed that nanostructured ZnO films exhibit a sharp near-band-edge luminescence peak at ~380 nm consistent with the estimated optical band gap and the ZnO nanorod arrays are notably free from defect-related green-yellow emission peaks.

INTRODUCTION

Zinc Oxide (ZnO) is one of the most promising II - VI group semiconductors generally crystallizes in the thermodynamically most stable hexagonal wurtzite structure. ZnO naturally exhibits n-type conductivity due to the formation of oxygen vacancies in the crystal lattice and has a wide direct band gap of 3.37 eV at room temperature [1-3]. Furthermore, ZnO is an environmentally benign, chemically stable and mechanically robust material and can be grown by number of deposition techniques[2, 4]. These intriguing properties together with wide range of multi-functionalities make ZnO material a potential candidate for a wide variety of applications[1, 2]. Recently, nano scale single crystalline ZnO materials such as nanorods (NRs), nanowires (NWs), nanotubes (NTs) etc. have been gained much attention because of their unique physical properties compared to their bulk counterpart. Synthesis of vertically aligned ZnO NRs along the *c*-axis direction is desirable for various device design and applications(for example ZnO/Cu₂O based radial-junction[3, 5]) in order to attain efficient charge carrier transport and collection [2]. Pre-depositing a *c*-axis textured ZnO thin seeding layer offers vital nucleation centers for growing vertically aligned ZnO NR assemblies along the substrate normal. In this study, three different techniques, namely, simple drop casting(DC), sol-gel-derived dip coating(DPC) and spin coating of ball-milled ZnO powder solution(BMD) have been employed for producing (0002) oriented ZnO thin seeding layers. ZnO Nanorods(NRs) were then grown by hydrothermal method atop these ZnO thin seed layers to elucidate the most effective ZnO seeding techniques for the growth of vertically-aligned ZnO NRs. The structural, morphological, optical and photoluminescence properties of ZnO NRs grown on ZnO seed thin films by three different techniques were investigated and discussed.

EXPERIMENTAL

Prior to actual seed layer deposition, all substrates were cleaned by sequential ultra-sonication in acetone, isopropanol, and finally in deionized (DI) water (Resistivity ~18MΩ.cm) each for 15 min followed by a hot air blown dry. *c*-Axis oriented ZnO thin seed layers grown by simple drop casting technique(ZnO(DC)) were reported previously[2]. Dip-coated ZnO thin seed layers(ZnO(DPC)) were grown on soda lime glass(SLG) from 0.020 M solution of Zinc acetate di-hydrate dissolved in ethanol. On the other hand, bulk ZnO powder (purity~99.99%) were ball-milled for 36 hours and then required amount of ball-milled powder(crystallite size(*LC*)~22 nm) were dispersed into absolute ethanol to make 0.020 M colloidal solution of ZnO. This solution was then spun-coated (~2500 rpm for 1 min) on FTO substrate for obtaining ZnO thin seed layers (ZnO(BMD)). All ZnO seed layers deposited by three techniques were annealed at 250 °C in the air for 1 hour. ZnO NRs were then deposited atop the bare as well as the ZnO seeded SLG and FTO substrates by hydrothermal method described elsewhere in detail[2]. The hydrothermally grown thin films were given to the same post-heat treatment as that of seeding layer (heated at 250 °C in the air for 1 hour) for removing any organic deposits from the bath solution.

The crystalline structure, surface morphology, optical and luminescent properties of the synthesized products were characterized by XRD (GBC scientific; Cu_K_{α1}: λ=1.54062 Å radiation source), SEM (Hitachi S3400N), UV-VIS-NIR spectrometer coupled with integrating sphere (Shimadzu 2600) and room temperature photoluminescence(RT-PL) spectrometer (PHOTON SYSTEM; excitation source: HeAg 30 Deep UV laser, λ_{ext} ≈ 224 nm; laser power < 1 mW) respectively.

RESULTS AND DISCUSSION

Figure 1 shows the normalized XRD patterns of ZnO(DC), ZnO(DPC) seed layers on SLG substrates and ZnO NRs on seeded SLG and FTO substrates as mentioned in the legend of the corresponding curve. The diffractogram of blank FTO substrate (gray curve) and pure ZnO powder (red curve) are also included in figure 1 for reference and comparison purposes. Pure ZnO powder exhibit

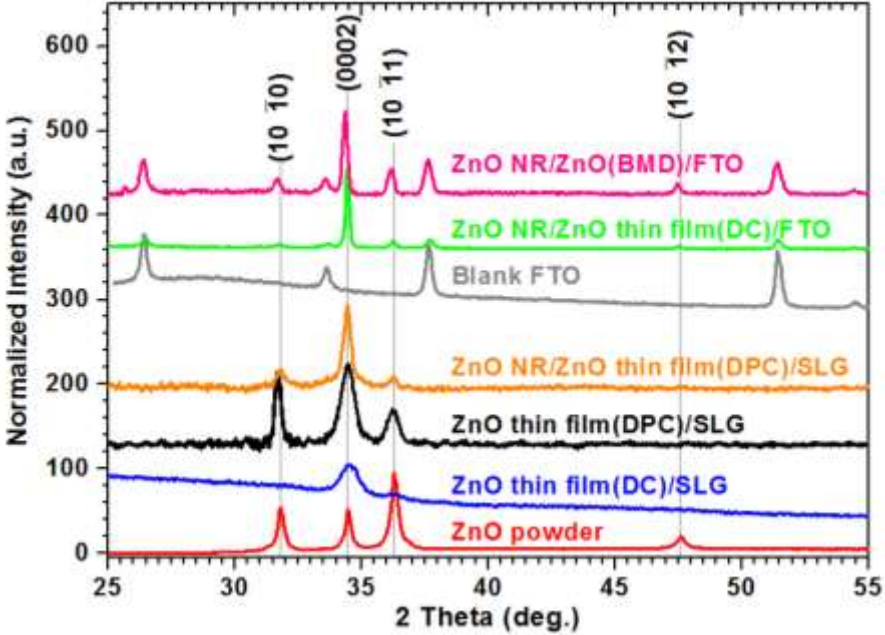


Figure 1. Normalized XRD patterns (vertically offset for clarity) of ZnO thin films and ZnO NRs deposited on seeded SLG and FTO substrates. Thin seed layers were prepared by drop casting(DP), dip-coating(DPC) and ball-milled derived(BMD) ZnO powder for spin coating of ZnO colloidal solution. The XRD pattern of bulk ZnO powder and blank FTO substrate are also included for comparison purposes.

well-defined Bragg peaks at $2\theta \approx 31.8^\circ$, 34.4° , 36.2° , and 47.6° which can be ascribed respectively to the (10 $\bar{1}$ 0), (0002), (10 $\bar{1}$ 1) and (10 $\bar{1}$ 2) reflection planes of hexagonal wurtzite structure. As can be seen, the diffractogram of ZnO(DC) seed layer exhibits a strong (0002) and a weak (10 $\bar{1}$ 1) reflection peak. In contrast, ZnO(DPC) seed layer exhibits Bragg peaks of (10 $\bar{1}$ 0), (0002), (10 $\bar{1}$ 1) planes without any preferred orientation. Note that the relative intensity of (0002) Bragg peak in the ZnO(DC) sample suggesting that ZnO seed layers were grown with a predominant *c*-axis texturing[6, 7]. The peak ratio $I(0002)/I(10\bar{1}1)$ was used to roughly estimate the amount of *c*-axis texturing of all deposited ZnO seed layers including ZnO NRs grown on ZnO(DC)/FTO, ZnO(DPC)/SLG, ZnO(BMD)/FTO seed layers and given in the table I. XRD patterns of ZnO NRs samples, regardless of substrate and seeding layer, are dominated by the (0002) basal plane reflections of wurtzite ZnO phase suggesting that ZnO NRs produced by hydrothermal method were grown along the *c*-axis[6-8], presumably parallel to the substrate normal[2]. The mean crystallite domain size(*LC*) were estimated to be $LC \sim 9$

nm for ZnO(DC)/SLG, $LC \sim 13$ nm for ZnO(DPC)/SLG, $LC \sim 24$ nm for ZnO NR/ZnO(DPC)/SLG, $LC \sim 45$ nm for ZnO NR/ZnO(DC)/FTO, and $LC \sim 43$ nm for ZnO NR/ZnO(BMD)/FTO by applying the Scherrer formula[2] to (0002) Bragg peak. Other important structural properties of ZnO nanostructured films were extracted from XRD analyses using similar approach employed in the reference[2] and summarized in table I for comparison purposes.

Table I. Structural properties obtained from X-ray diffractogram analysis.

Structural Parameters	ZnO(DC) seed/SLG	ZnO(DPC) seed /SLG	ZnO NRs On ZnO (DPC)/SLG	ZnO NRs on ZnO (DC)/FTO	ZnO NRs on ZnO (BMD)/FTO
$2\theta(0002)$ (deg.)	34.44	34.45	34.46	34.46	34.36
$d(0002)$ (nm)	0.26024	0.26017	0.26009	0.26009	0.26083
a (nm)	0.31873	0.31864	0.31855	0.31855	0.31945
c (nm)	0.52048	0.52034	0.52019	0.52019	0.52166
FWHM (deg.)	0.927	0.640	0.347	0.184	0.192
Mean crystallite domain size (nm)	8.87	12.85	23.70	44.70	42.83
$I(0002)/I(10\bar{1}1)$	17.00	2.70	7.00	11.00	3.00
Strain(ϵ_{zz}) $\times 10^{-3}$	0.282	0	-0.281	-0.281	0.254
Stress(GPa)	-0.12	0	0.13	0.13	-1.14

As can be seen from table I, the c -axis texturing ($TC = I(0002)/I(10\bar{1}1)$) for ZnO(DC)/SLG is ~ 17 which is the highest among the samples studied and ~ 6 times higher compared to that of the ZnO(DC)/SLG seed layer. For NRs grown on seeded substrates: $TC \sim 7.00$ for ZnO NR/ZnO(DPC)/SLG, $TC \sim 11.00$ for ZnO NR/ZnO(DC)/FTO, and $TC \sim 3.00$ for ZnO NR/ZnO(BMD)/FTO. These observations suggest that c -axis textured ZnO(DC) seed layer indeed facilitates the formation of c -axis oriented ZnO NRs along the substrate normal[2, 6-8]. Considering only the similar sample structure, the estimated biaxial stress in ZnO NR/ZnO(BMD)/FTO and ZnO NR/ZnO(DC)/FTO are found compressive and tensile respectively. Mechnache *et. al.* [9] reported similar observations for their ZnO NR film grown on glass, ITO/glass and AZO/glass substrates by spray pyrolysis at $T_{sub} = 350$ °C and argued that the observed the change from compressive stress for ZnO NR/glass to tensile stress for ZnO NR/ITO/glass and ZnO NR/AZO/glass are due to the improvement of c -axis texturing.

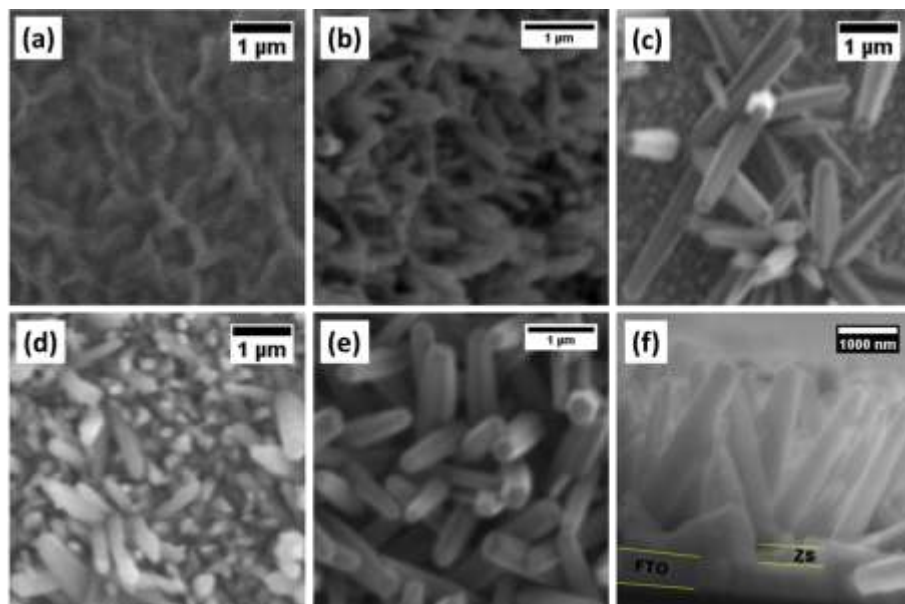


Figure 2. SEM micrographs of ZnO(DPC)/SLG (a), ZnO NR/ZnO(DPC)/SLG (b), ZnO NR/FTO (c); ZnO NR/ZnO(BMD)/FTO (d), ZnO NR/ZS(DC)/FTO (e) and ZnO NR/ZS(DP)/FTO (f). (a) – (e) are plane view images and (f) is the cross-sectional view image.

Figure 2(a – e) compares the surface morphology ZnO NRs grown atop the seeded and non-seeded layers. The morphology of ZnO seed layer surface is seen to be compact and coherently carpets the underlying substrate (see figure 2(a) and 2(f)) throughout the area investigated. As can be seen, ZnO NRs grown on ZnO(BMD) seed (figure 2(d)) are irregular-shaped and randomly oriented. ZnO NRs grown on ZnO(DPC) seed (figure 2(b)) are seen to be thin nanorods with no clearly defined hexagonal facets and they are poorly oriented. In contrast, ZnO NRs grown on blank FTO (figure 2(c)) and ZnO(DC) seeded FTO (figure 2(e)) exhibit well-defined hexagonal facets. Notice that FTO substrate seeded with ZnO(DC) produced the best aligned ZnO NRs among the samples investigated and they are basically vertically-oriented nanorods arrays as evident from the cross-sectional image of the same sample (figure 2(e)). In figure 2(e), ZnO(DC) seed layer (labeled by ZS, thickness $\sim 232 \pm 34$ nm), FTO substrate (thickness $\sim 608 \pm 22$ nm), and vertically grown ZnO NRs (Length $\sim 3.2 \pm 0.1$ μm) are evidently seen in the cross-sectional view of ZnO NR/ZnO(DC)/FTO film. Clearly, *c*-axis oriented ZnO(DC) seed layer produced highly *c*-axis textured ZnO NRs evident from both XRD and SEM analyses (see figure 1 and figure 2). These observations also demonstrate the beneficial effect of pre-depositing of an oriented ZnO seed layer for the subsequent hydrothermal growth of vertically-aligned ZnO NRs along the *c*-axis.

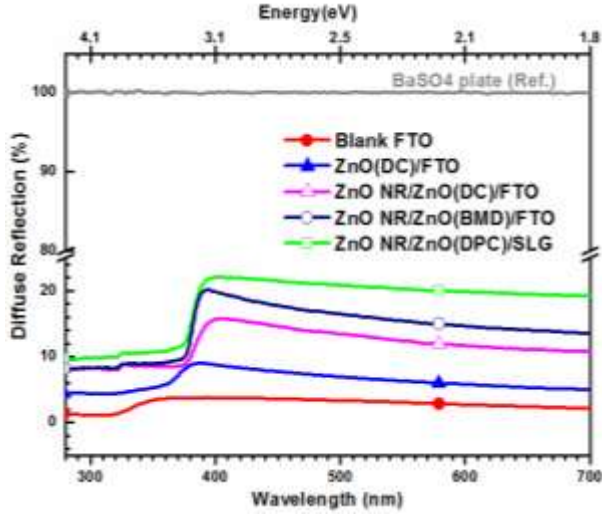


Figure 3. Diffuse reflection spectra of nanostructured ZnO thin films grown on SLG and FTO substrates. Diffuse Reflection data of blank FTO substrate is also included in the graph for comparison purposes.

Figure 3 compares the diffuse reflection data of ZnO(DC) thin film(solid triangle) and ZnO NRs grown on ZnO(DC) seed layer(open triangle), ZnO(DPC) seed layer (open rectangle) and ZnO(BMD) seed layer(open circle) including blank FTO substrate(solid circle). The optical band gap(E_g) of these samples were estimated from the Tauc plot generated by using diffuse reflection data together with the so-called Kubelka-Munk function($F(R_\infty)$)[2] and displayed in figure 4 below.

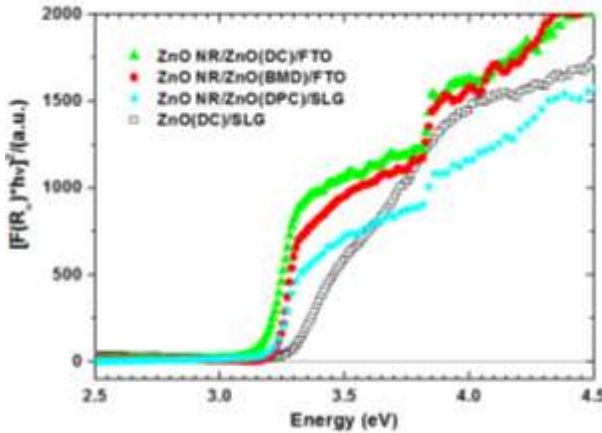


Figure 4. Tauc plot for estimating band gap using diffuse reflection data of ZnO(DC)/SLG (open rectangle), ZnO NR/ZnO(DPC)/SLG (solid star), ZnO NR/ZnO(BMD)/FTO (solid circle) and ZnO NR/ZnO(DC)/FTO (solid triangle) thin films.

As can be seen from figure 4, the optical band gap for ZnO(DC)/SLG, ZnO NR/ZnO(DPC)/SLG, ZnO NR/ZnO(BMD)/FTO, and ZnO NR/ZnO(DC)/FTO were

estimated to be ~3.30 , ~3.20 , ~3.25 and ~3.18 eV respectively and they are in good agreement with the reported band gap of nanostructured ZnO thin films([2] and refs. therein). To supplement optical band gap measurements of nanostructured ZnO film as well as to identify defect-related emission, PL measurements were also carried out at room temperature and depicted in figure 5 below. Form the literature, most PL spectra of ZnO thin film[10-12] and ZnO NRs[8, 13-15] show both the 380 nm UV emission feature and a much broader emission feature in the visible region(500 – 600 nm)[13]. The luminescent peak centering at~380 nm has been attributed to the near-band-edge(NBE) transition of ZnO due to the recombination of free excitons, while the luminescent features in the visible region have been attributed to the various defects, such as oxygen vacancies(V_o), oxygen interstitials(O_i) and zinc interstitials(Zn_i) etc., present in the ZnO crystal lattice[13, 14]. Therefore, the quality of synthesized ZnO can be assessed simply by estimating the ratio of the UV and Visible luminescent peak intensities (I_{uv}/I_{vis})[15].

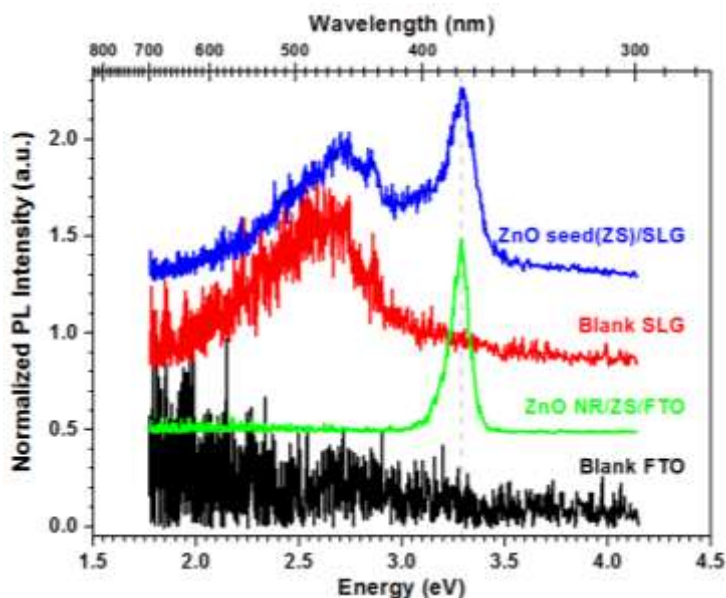


Figure 5. Normalized PL spectra (vertically offset for clarity) of ZS , ZnO NRs films, blank SLG, and blank FTO substrate recorded at room temperature. The PL intensity is normalized with respect to the highest peak height for all samples. The broad peak at ~2.6 eV (~490 nm) in panel originates from underlying SLG substrate.

In figure 5, the PL spectra of blank SLG(red curve) and FTO substrate (black curve) are compared and contrasted with that of ZnO(DC)/SLG(blue curve) and ZnO NR/ ZnO(DC)/FTO(green curve) thin films. Notice the PL spectrum of blank FTO substrate is featureless. In ZnO(DC)/SLG(blue curve) sample, the broad band feature centering at ~2.6 eV (~490 nm) in the PL spectra may originate from the underlying SLG substrate, as this feature is absent in the relatively thicker and dense ZnO NR/ ZnO(DC)/FTO(green curve) films(see also figure 2(e) and 2(e)). Strikingly, both ZnO(DC)/SLG and ZnO NR/ZnO(DC)/FTO sample displayed a sharp near-band-edge (NBE) at ~378 nm (~3.25 eV) and barely detectable green-yellow emission peak(s) in the RT-PL spectra. This PL feature is indicating high crystalline quality of our drop casting synthesized ZnO seed and hydrothermally grown ZnO NRs on ZnO(DC) seed[2, 15]

presumably with no or very low defect densities. In addition, the NBE value (~ 3.25 eV) from PL spectra is reasonably in good agreement with the estimated optical band gap ($\sim 3.18 - 3.25$ eV) of the ZnO NRs using diffuse reflection data. It is worth noting that both ZnO(DC) and ZnO NR grown by facile chemical routes produced defect free good crystalline and optical quality materials, which is desirable for ZnO/Cu₂O based device applications[3]. Further experimental investigations are currently in progress to confirm the presence of green-yellow defects in hydrothermally grown ZnO NRs atop the BMD seed layer and the DPC seed layer with and without post-heat treatment in different ambient conditions.

CONCLUSIONS

In summary, ZnO seed layer have been successfully deposited by three different techniques and among them drop casted ZnO seed layers exhibit the highest *c*-axis texturing evident from the XRD analyses. XRD analyses also evidenced that ZnO NRs hydrothermally grown on ZnO(DC) seed exhibit high *c*-axis texturing compared to those grown on other seed layers. The SEM micrographs reveal that pre-depositing a ZnO seed layer is beneficial for growing aligned ZnO NRs along the *c*-axis direction parallel to the substrate normal. The optical band gap of nanocrystalline ZnO seed and ZnO NRs estimated by the UV-VIS-NIR spectroscopy were found to be 3.30 eV and in the range 3.18 – 3.25 eV respectively and consistent with the reported results in the literature. The RT-PL analyses further confirmed that ZnO NRs grown on ZnO(DC) seeded substrate are single crystalline like and free from defect-related green-yellow emission peaks.

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